4-25-200

					Docket Number (Optional) NEC01P024-IN		Application Number		d		
•	יחזא	RMATION DISCLOSURE	CITATION		NEC01P024-JN Applicant(s)	<u></u> ]	None Yet Assigned				
	,	(Use several sheets if necessa	(יכי		Syuji Matsuo et al.	<del></del> -	Group Art Unit				
•	•				Filing Date Concurrently Here			t Assigned	<u> </u>		
U.S. PATENT DOCUMENTS											
'EXAMINER INITIAL	REF	P DOCUMENT NUMBER DATE		T	NAME CLASS		SUBCLASS FILING DAT				
\			1								
+				1				PTG			
+ -			<del>                                     </del>	1		<del>                                     </del>		4096	2/01		
+-			+					170	2/4/2		
			1			7.22	+	60			
				<del></del>		<del> </del>	<del>                                     </del>	<del>                                     </del>			
			<del>                                     </del>	+		<del> </del>		<del>                                     </del>			
			-			<del>                                     </del>		<del>                                     </del>			
			<del> </del>	-		<del> </del>	_				
	-		<del> </del>	+			+				
				-					7		
						<u> </u>					
			<del></del>	FOREIG	N PATENT DOCUMENTS	т	<del></del>	T	L d : -		
	REF	DOCUMENT NUMBER	DATE		COUNTRY CLASS		SUBCLASS	YES NO			
900		11-4240	01/06/99	JAPAN				ABS			
940		10-170606	06/26/98	JAPAN	1			ABS			
1											
			, i								
1								-			
<u> </u>	·	<b></b>		OTHER	DOCUMENTS (Including	Author, Title,	Date, Pertinent Pa	ges, Etc.)			
	$\overline{\mathbf{x}}$	Motohiko Inad						_			
94	• 1	"An Introduction to II	EEE Standard 1	394" , Seco	ond Edition, Chapter 2, Gij	jyutsu-Hyor ———	ron Co. Ltd.				
\						_ <del></del>					
							1				
EXAMINE		9m N M	re		DATE CONSIDERED	219					
EXAMINE considered.	EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.										

6-30-2003

					Docket Number (Optional) NEC01P024-JNb		Application Number				
" INFORMATION DISCLOSURE CHAPTEON						Applicant(s)	09/840,967				
			(Use several sheets if necesse	45P'' - 2	N I	Syuji Matsuo, et al.					
ŀ	0 2000				Filing Date April 25, 200		Group Art Unit 2631				
JU.S. PATENT DOCUMENTS											
*EXAMINER	MINER REF DOCUMENT NUMBER		TO A POETUBARY	<b>y</b>	NAME	CLASS	SUBCLASS	FILING DATE			
*******	$\vdash$	+-	-				+	+	IF APPRO	PRIATE	
	<u> </u>	_		<del> </del>	ļ		<del> </del>		L		
		_			<u> </u>						
		<u> </u>			ļ			·	ļ		
						*					
								JUL 0 1 ?	/FD		
					IP,		H	ECLI			
<del>                                     </del>				<del> </del>				DUL 0 1 7	1903		
		<del> </del>		-			To	HANING CE	nter 260	<b>0</b>	
							ilei	Millionogy -			
,	İ						<u> </u>				
					FOREIGN	N PATENT DOCUMENTS					
	REF		DOCUMENT NUMBER	DATE		COUNTRY	CLASS	SUBCLASS	Transi	lation NO	
920		9-214502		08/15/1997	Japan				ABS		
Jan		11-4240		01/06/1999	Japan				ABS		
\											
					OTHER D	OOCUMENTS (Including A	Author, Title, E	Pate, Pertinent Pa	ges, Etc.)		
\			Japanese Office Action	dated April 2, 200	03 with Par	rtial English Translation.					
	十										
EXAMINER OM N MUL DATE CONSIDERED 2/9/05											
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.											

Form PTO-A820 (also form PTO-1449) P09A/REV04

Patent and Trademark Office \* U.S. DEPARTMENT OF COMMERCE